

Substitute for form 1449/PTO

**Complete if Known**

Application Number	10/816,337
Filing Date	March 31, 2004
First Named Inventor	John M. de Larios
Art Unit	1744
Examiner Name	Kornakov, Michail
Attorney Docket Number	LAM2P464

**INFORMATION DISCLOSURE  
STATEMENT BY APPLICANT**

(Use as many sheets as necessary)

Sheet 1 of 3

**U.S. Patent Documents**

Examiner Initials	Cite No. <sup>1</sup>	Document Number	Issue or Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, where Relevant Passages or Relevant Figures Appear
		Number-Kind Code <sup>2</sup> (if known)			
LCG	AA	2002-0094684-A1	07-18-2002	Hirasaki et al.	
LCG	BA	2002-0195121-A1	12-26-2002	Kittle	
LCG	CA	2003-0075204-A1	04-24-2003	De Larios et al.	
LCG	DA	2003-0171239-A1	09-11-2003	Patel et al.	
LCG	EA	3,978,176	08-31-1976	Voegeli	
LCG	FA	4,838,289	06-13-1989	Kottman et al.	
LCG	GA	5,271,774	12-21-1993	Leenaars et al.	
LCG	HA	5,464,480	11-07-1995	Matthews	
LCG	IA	5,705,223	01-06-1998	Bunkofske	

**Foreign Patent Documents**

Examiner Initial	Cite No. <sup>1</sup>	Foreign Patent Document No.	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, where Relevant Passages or Relevant Figures Appear	T <sup>6</sup>
		Country Code <sup>3</sup> -Number-Kind Code <sup>5</sup> (if known)				
LCG	JA	JP-2002-280330-A	09-27-2002	Lintec Corp		<input type="checkbox"/>
LCG	KA	JP-2002-309638-A	10-23-2002	Takiron Co. Ltd.		<input type="checkbox"/>
LCG	LA	JP-H11-350169-A	12-21-1999	Chemitoronics Co.		<input type="checkbox"/>
LCG	MA	JP-S62-119543-A	05-30-1987	Mitsubishi Electric Corp.		<input type="checkbox"/>
	NA					<input type="checkbox"/>

**Non Patent Literature Documents**

Examiner Initial	Cite No.	Include name of author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published	T <sup>6</sup>
LCG	OA	KIRKPATRICK et al., "Advanced Wafer-Cleaning Evolution," Solid State Technology, May 2003, www.solid-state.com	<input type="checkbox"/>
LCG	PA	WEAIRE et al., "The Physics of Foams," Department of Physics, Trinity College, Dublin, 1999	<input type="checkbox"/>
LCG	QA	KITTLE et al., "Photoresist Removal Using Aqueous Foam," found on the internet: <a href="http://www.aquafoam.com/papers/A2C2photoresist.pdf">http://www.aquafoam.com/papers/A2C2photoresist.pdf</a> , 2001	<input type="checkbox"/>
LCG	RA	KITTLE et al., "Aqueous Foam Drying and Cleaning of Semiconductor Wafers," found on the internet: <a href="http://www.aquafoam.com/papers/SCCPresentation.pdf">http://www.aquafoam.com/papers/SCCPresentation.pdf</a>	<input type="checkbox"/>

Examiner Signature	/Laura C Guidotti/	Date Considered	06/09/2006
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LCG	AB	5,858,283	01-12-1999	Burris	
LCG	BB	5,900,191	05-04-1999	Gray et al.	
LCG	CB	5,945,351	08-31-1999	Mathuni	
LCG	DB	5,997,653	12-07-1999	Yamasaka	
LCG	EB	6,267,125	07-31-2001	Bergman et al.	
LCG	FB	6,276,459	08-21-2001	Herrick et al.	
LCG	GB	6,398,975	06-04-2002	Mertens et al.	
LCG	HB	6,439,247	08-27-2002	Kittle	
LCG	IB	6,491,764	12-10-2002	Mertens et al.	

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		Country Code <sup>3</sup> -Number- <sup>4</sup> Kind Code <sup>5</sup> (if known)				
	JB					<input type="checkbox"/>
	KB					<input type="checkbox"/>
	LB					<input type="checkbox"/>
	MB					<input type="checkbox"/>
	NB					<input type="checkbox"/>

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LCG	OB	KITTLE et al., "Foam Wafer Cleaning - Experimental Proof of Concept < <a href="http://www.aquafoam.com/papers/Removalall.pdf">http://www.aquafoam.com/papers/Removalall.pdf</a> >"	<input type="checkbox"/>
LCG	PB	KITTLE, et al., "Particulate Removal Using a Foam Medium < <a href="http://www.aquafoam.com/papers/particulate.pdf">http://www.aquafoam.com/papers/particulate.pdf</a> >"	<input type="checkbox"/>
LCG	QB	KITTLE, "Removing Particles with a Foam Medium < <a href="http://www.aquafoam.com/papers/A2C2foammedium.pdf">http://www.aquafoam.com/papers/A2C2foammedium.pdf</a> >," A2C2, page 11-15, January, 2002	<input type="checkbox"/>
LCG	RA	KITTLE et al., "Photoresist Residue Removal Using Aqueous Foam Proof of Concept Experiments < <a href="http://www.aquafoam.com/papers/Proof-11MB.pdf">http://www.aquafoam.com/papers/Proof-11MB.pdf</a> >" < <a href="http://www.aquafoam.com/papers/A2C2photoresist.pdf">http://www.aquafoam.com/papers/A2C2photoresist.pdf</a> >, pages 13-17, May, 2002	<input type="checkbox"/>

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	BC				
	CC				
	DC				
	EC				
	FC				
	GC				
	HC				
	IC				

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		Country Code <sup>3</sup> -Number- <sup>4</sup> Kind Code <sup>5</sup> (if known)				
	JC					<input type="checkbox"/>
	KC					<input type="checkbox"/>
	LC					<input type="checkbox"/>
	MC					<input type="checkbox"/>
	NC					<input type="checkbox"/>

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LCG	OC	KITTLE et al., "Semiconductor Wafer Cleaning and Drying Using a Foam Medium" < <a href="http://www.aquafoam.com/papers/NWCWG.pdf">http://www.aquafoam.com/papers/NWCWG.pdf</a> > Sematech Novel Wafer Cleans Working Group Meeting, Internet Presentation, November 13, 2001	<input type="checkbox"/>
LCG	PC	HUNTER, "Introduction to Modern Colloid Science," Oxford University Press, February 1994	<input type="checkbox"/>
LCG	QC	LESTER "Is Foam Wafer Cleaning and Drying the Future? " < <a href="http://www.aquafoam.com/papers/SCI0202.pdf">http://www.aquafoam.com/papers/SCI0202.pdf</a> > Semiconductor International, 25, #2 (February), 42 (2002).	<input type="checkbox"/>
	RC		<input type="checkbox"/>

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LCG	AA	6,272,712	08/14/2001	Gockel et al.	Column 14, line 57 – column 16, line 32; figure 14, abstract.
	BA				
	CA				
	DA				
	EA				
	FA				
	GA				
	HA				
	IA				

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		Country Code <sup>3</sup> -Number- <sup>4</sup> Kind Code <sup>5</sup> (if known)				
LCG	JA	WO 00/59006 A	10/05/2000	Philips Electronics	Abstract; figures 6a, 6b, 8; page 14, line 15 – page 18, line 4.	<input type="checkbox"/>
	KA					<input type="checkbox"/>
	LA					<input type="checkbox"/>
	MA					<input type="checkbox"/>
	NA					<input type="checkbox"/>

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	OA		<input type="checkbox"/>
	PA		<input type="checkbox"/>
	QA		<input type="checkbox"/>
	RA		<input type="checkbox"/>

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